

## Article

# Photon-phonon atomic coherence interaction of non-linear signals in various phase transitions $\text{Eu}^{3+}$ : $\text{BiPO}_4$

Huanrong Fan<sup>#</sup>, Faizan Raza<sup>#</sup>, Irfan Ahmed, Muhammad Imran, Faisal Nadeem, Changbiao Li<sup>\*</sup>, Peng Li<sup>\*</sup>, and Yanpeng Zhang<sup>\*</sup>

Key Laboratory for Physical Electronics and Devices of the Ministry of Education & Shaanxi Key Lab of information Photonic Technique, Xi'an Jiaotong University, Xi'an 710049, China; 495356182@qq.com (H.F.); faizanraza17@outlook.com (F.R.); irfan.ahmed@my.cityu.edu.hk (I.A.); imran89@mail.xjtu.edu.cn (M.I.); faisalnadeem15@stu.xjtu.edu.cn (F.N.); cbli@mail.xjtu.edu.cn (C. L.); ponylee@stu.xjtu.edu.cn (P.L.); ypzhang@mail.xjtu.edu.cn (Y.Z.)

\* Correspondence: ypzhang@mail.xjtu.edu.cn, ponylee@stu.xjtu.edu.cn, cbli@mail.xjtu.edu.cn

# These authors contributed equally to this work.

**Abstract:** We report photon-phonon atomic coherence (cascade- and nested-dressing) interaction from various phase transitions of  $\text{Eu}^{3+}$ :  $\text{BiPO}_4$  crystal. Such atomic coherence spectral interaction evolves from out of phase fluorescence to in-phase spontaneous four-wave mixing (SFWM) by changing the time gate. The dressing dip switch and three dressing dips of SFWM result from strong photon-phonon destructive cross- and self-interaction for hexagonal phase, respectively. The more phonon dressing result in destructive interaction, while less phonon dressing result in constructive interaction of atomic coherences. The experimental measurements of photon-phonon interaction agree with theoretical simulations. Based on our results, we proposed a model for an optical transistor (as an amplifier and switch).

**Keywords:** atomic coherence, spectral interaction, phonon/photon dressing; spontaneous four-wave mixing

## 1. Introduction

In the past years, it was desirable to couple a single like-atom spin to a superconducting qubit, where a nanomechanical resonator is coupled to a two-level system to induce strong phonon-phonon interactions [1-2]. However, the entanglement generated is affected by different systems in a traditional method that often needs a strong spin-phonon interaction to exceed the decay of the phonons [3-4]. Phonon dispersion relation and lattice-spin coupling of  $\text{Eu}^{3+}$  have been reported [5-6]. Thermal phonon at elevated temperatures, lattice vibration structural transition, and thermal expansion behavior in  $\text{LaPO}_4$ : Eu have been also studied [7].

Recently, the photon-phonon dressing coupling in  $\text{Eu}^{3+}$  ions doped  $\text{BiPO}_4$  has been studied [8-9], as  $\text{Eu}^{3+}$ /  $\text{Pr}^{3+}$  ions are very sensitive to the site symmetry and its surrounding crystal field of the host material than other crystal ions [10-12]. Therefore, it can be achievable to get such kind of potential application in  $\text{BiPO}_4$  crystal. The crystal structure of  $\text{BiPO}_4$  has two polymorphic forms, monoclinic (M)- and hexagonal (H)-phases. The difference in the symmetry of the lattice structure results in different interactions [13-14]. The H-phase of crystal is more structurally asymmetric than the M-phase in  $\text{Eu}^{3+}$  because of a more atomic-like system. Bismuth phosphate ( $\text{BiPO}_4$ ) has drawn significant attention as a host medium for doping lanthanide ions due to its comparable ionic radius of  $\text{Bi}^{3+}$  (1.11 Å) with that of lanthanide ions [15-17].

The  $\text{Eu}^{3+}:\text{BiPO}_4$  is one of the most promising atomic-like mediums known for its long coherence time (ms) [8] due to photon-phonon coupling in doubly dressed states with potential applications in quantum memory [18-20].

Interactions of doubly dressed states and the corresponding properties of atomic systems have attracted considerable attention in recent decades. In this regard, two kinds of doubly dressed processes (in cascade- and nested-parallel schemes) were reported in an open five-level atomic system [21-22]. Nie et al theoretically investigated the similarities and differences between different kinds of singly dressing schemes for six-wave mixing to examine the interaction between multi-wave mixing in a five levels atomic system [23].

Next, we will consider such multi-nonlinear signals interaction with the coupling of lattice vibration phonon and photon dressing.

In this paper, we investigated two multi-dressing cross-interaction obtained from various phase transitions of  $\text{Eu}^{3+}:\text{BiPO}_4$  crystal by changing time gates. The spectral cross-interaction evolves from out of phase FL, to hybrid (FL+SFWM), and to in-phase SFWM (anti-Stokes signal). Moreover, we demonstrate that the FL and SFWM destructive interaction results from more phonon dressing, and such dressing is achieved with multiparameter temperature (300K), H-phase, and broadband excitation.

## 2. Experimental Scheme

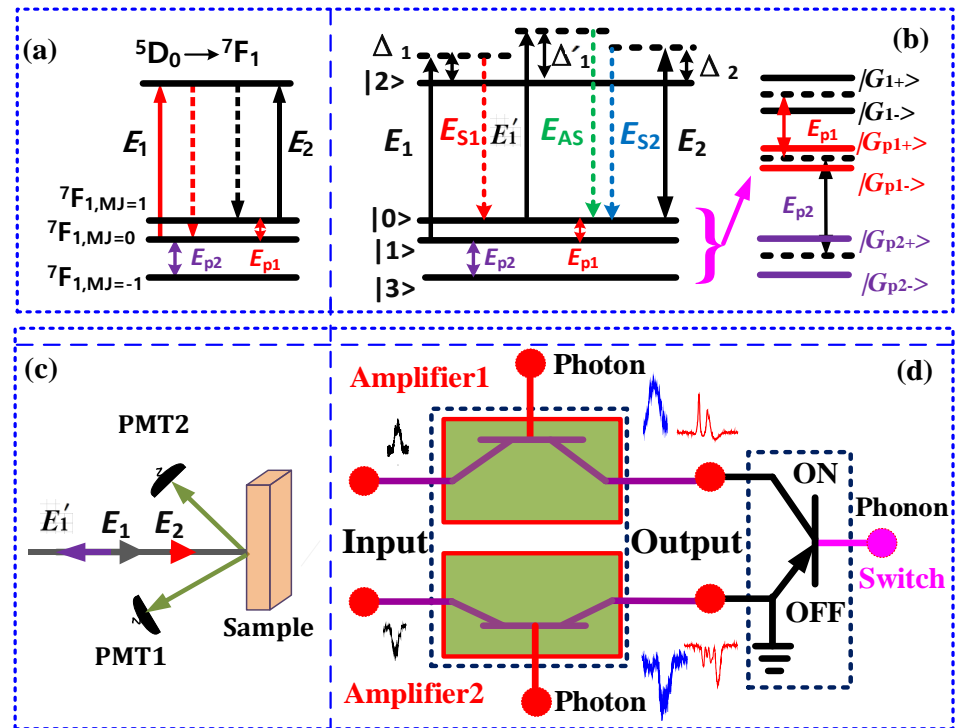
The ion  $\text{PO}_4^{3-}:\text{[Bi}^{3+}+\text{Eu}^{3+}]$  has five molar ratios (7:1, 20:1, 6:1, 1:1, 0.5:1) for  $\text{Eu}^{3+}:\text{BiPO}_4$  sample with different lattice vibration structures. In our experiment (Fig.1(c)), we used five  $\text{BiPO}_4$  samples with different combinations and concentrations of pure H-phase and low-temperature monoclinic phase (LTMP), where H-phase refers to  $\text{C}_2$ , and LTMP refers to  $\text{C}_1$  site symmetry, respectively. The sample (7:1) corresponds to the pure M-phase, (20:1) corresponds to the mixed [more M (75%) + less H (25%)] phase, (6:1) corresponds to the mixed [half H (50%) + half M (50%)] phase, (1:1) corresponds to the mixed [less H (25%) + more M (75%)] phase, and (0.5:1) corresponds to the pure-H phase. The concentration of  $\text{Eu}^{3+}$  ions is 5% consistent across all five samples with different phase transitions. Figure 1(a) shows the fine structure energy levels of  $\text{Eu}^{3+}:\text{BiPO}_4$  crystals. The  $\text{Eu}^{3+}:\text{BiPO}_4$  has ground state  $^7\text{F}_1$  and excited state  $^5\text{D}_0$  ( $m_j=0$ ), the ground state  $^7\text{F}_1$  can split into  $m_j=-1$  (587.3nm),  $m_j=0$  (592.3nm), and  $m_j=+1$  (597.3nm) under the crystal field effect of  $\text{BiPO}_4$  crystal.

To implement the experiment,  $\text{Eu}^{3+}:\text{BiPO}_4$  samples were held in a cryostat (CFM-102). The temperature was controlled through liquid nitrogen from 300K (large phonon Rabi frequency  $G_{pi}^T$  with more thermal phonons) to 77K, where  $G_{pi}^T = -\mu_{kl}E_{pi}/\hbar$  is the Rabi frequency of phonon field ( $i=1, 2$ ;  $T=(T_1, T_2)=(300\text{K}, 77\text{K})$ ). The  $\mu_{kl}$  is the dipole moment between  $|k\rangle$  and  $|l\rangle$  of crystal field splitting in  $^7\text{F}_1$  state (Fig. 1(b)),  $E_{pi}$  is the phonon field, where such phonon builds atomic coherence for crystal field splitting in  $^7\text{F}_1$ .

In the experiment, the  $G_{pi}^T$  and phase transition detuning  $\Delta_{pi}^j$  are controlled by temperature and different samples, respectively. The frequency detuning of phonon field is  $\Delta_{pi}^j = \Omega_{kl} - \omega_{pi}^j$  ( $j=a(7:1)$ ,  $b(20:1)$ ,  $c(6:1)$ ,  $d(1:1)$  and  $e(0.5:1)$  sample) in Figure. 1(b), where  $\Omega_{kl}$  is the frequency between  $|k\rangle$  and  $|l\rangle$ . The  $\omega_{pi}^j$  is the phonon frequency of the phonon field, which is determined by the vibration frequency of crystal lattice state mode. The different frequencies of phase transitions ( $\omega_{pi}^a < \omega_{pi}^e$ ,  $\Delta_{pi}^a > \Delta_{pi}^e$ ) can couple to different lattice vibrations for  $\text{Eu}^{3+}:\text{BiPO}_4$ , resulting in different phonon dressing ( $|G_{pi}^T|^2/i\Delta_{pi}^a < |G_{pi}^T|^2/i\Delta_{pi}^e$ ).

**Figure 1(c)** shows the schematic diagram of the experimental setup. Here we used two tunable dye lasers (narrow scan with a  $0.04\text{cm}^{-1}$  linewidth) pumped by an injection-locked single-mode  $\text{Nd}^{3+}:\text{YAG}$  laser (Continuum Powerlite DLS 9010, 10Hz repetition

rate, 5ns pulse width) to generate the pumping fields broadband  $E_1$  ( $\omega_1$ ,  $\Delta_1$ ) and narrow-band  $E_2$  ( $\omega_2$ ,  $\Delta_2$ ). Broadband excitation  $E_1$  couples to more crystal field splitting levels  $^5D_0$  and  $^7F_1$  (Fig. 1(b)), resulting in more lattice vibration (phonon dressing). However, narrowband excitation  $E_2$  couples to fewer splitting levels, resulting in less lattice vibration. The frequency detuning here is  $\Delta_i = \Omega_{mn} - \omega_i$ , where  $\Omega_{mn}$  is the frequency between crystal field splitting levels  $^5D_0$  and  $^7F_1$ ,  $\omega_i$  is the optical frequency. The Rabi frequency of the optical field is defined as  $G_i = -\mu_{mn}E_i / \hbar$ , where  $\mu_{mn}$  is the dipole moment of the crystal field splitting with different states  $^5D_0$  and  $^7F_1$  excited by  $E_i$  between levels  $|m\rangle$  and  $|n\rangle$  in Fig. 1(b). Such photon builds atomic coherence of crystal field splitting with different states ( $^5D_0$  and  $^7F_1$ ). The pulse generated from Nd<sup>3+</sup>: YAG laser is used to simultaneously trigger a boxcar gated integrator and oscilloscope. The input laser beams are along the [010] axis of the BiPO<sub>4</sub> crystal, which is perpendicular to the optical axis. The spectral optical outputs are obtained by scanning laser frequency. The grating motor of two dye lasers is scanned by a computer to form the x-axis, and the intensity of the excitation spectrum is the average of ten shots from the gated integrator (Fig. 1(c)) appearing on the y-axis.



**Fig. 1** (a) Show energy levels of Eu<sup>3+</sup>: BiPO<sub>4</sub> for transition  $^7F_1 \rightarrow ^5D_0$ , (b) Show photon and phonon four dressing energy level. (c) Experimental setup. (d) The schematic diagram of proposed optical transistor as an amplifier and switch.

The optical signal generated from Eu<sup>3+</sup>: BiPO<sub>4</sub> crystal is detected via confocal lenses at photomultiplier tubes (PMTs). In our experiment setup, PMT1 is precisely placed to detect the narrowband FL and spontaneous four-wave mixing (SFWM) signal whereas PMT2 is placed to detect the broadband FL and SFWM signal. Such detector placement is

based on the different distances from the detector to the sample (Fig. 1(c)). Hence, PMT affects the ratio of out of phase FL and in-phase SFWM. The out of phase FL1 signal and FL2 signals are generated through excitation of  $E_1$  and  $E_2$  lasers, respectively. The in-phase  $E_{s1}$  signal is generated by a combination of  $E_1$  and reflection  $E'_1$  under phase-matched condition ( $k_1 + k'_1 = k_s + k_{AS}$ ). At the same time, the spectral signals from different energy levels with different lifetimes can be obtained through boxcar gated integrators which can be controlled from the time gate. The time gate can control the ratio of out of FL and  $E_{s/AS}$ .

Therefore, photon-phonon atomic coherence interaction can be controlled by changing the time gate, broadband/narrowband excitation, and thermal/phase transition phonon.

## 2.1. Theoretical Model

### A. Photon-photon atomic coherence cross-interaction

The single laser or two lasers excitation shows photon dressing. Different lattice vibrations produced different frequency phonons. Such different frequency phonon can match to different crystal field splitting levels  $^5D_1-^7F_1$ ,  $^5D_0-^7F_1$ , and  $^5D_0-^7F_3$  in the ion  $Eu^{3+}$ , so more phonon results in effective dressing. The three sharp dips are hard to be explained only by photon field dressing. Therefore, phonon can be used to explain three sharp dips. The cross-interaction evolves from FL to hybrid (coexistence of second order FL and SFWM), to SFWM are below

$$|\rho_{F1}^{(2)} + \rho_{F2}^{(2)}|^2 = |\rho_{F1}^{(2)}|^2 + |\rho_{F2}^{(2)}|^2 + 2|\rho_{F1}^{(2)}||\rho_{F2}^{(2)}|\cos(\theta_F), \quad (1)$$

$$|\rho_{AS1}^{(3)} + \rho_{AS2}^{(3)}|^2 = |\rho_{AS1}^{(3)}|^2 + |\rho_{AS2}^{(3)}|^2 + 2|\rho_{AS1}^{(3)}||\rho_{AS2}^{(3)}|\cos(\theta_{AS}), \quad (2)$$

$$|\rho_H^x|^2 = |\rho_{F1}^{(2)} + \rho_{F2}^{(2)} + \rho_{S1}^{(3)} + \rho_{S2}^{(3)}|^2. \quad (3)$$

When the laser field  $E_1$  and  $E_2$  are applied, the density matrix elements of out of phase FL for [H+M]-phase  $Eu^{3+}$ :  $BiPO_4$  via perturbation chain  $\rho_{11}^{(0)} \xrightarrow{E_1} \rho_{12}^{(1)} \xrightarrow{(E_1)^*} \rho_{22}^{(2)}$  and

$\rho_{00}^{(0)} \xrightarrow{E_2} \rho_{20}^{(1)} \xrightarrow{(E_2)^*} \rho_{22}^{(2)}$  can be written as  $\rho_{F1}^{(2)} = -|G_1|^2 / ((\Gamma_{12} + i\Delta_1 + |G_2|^2 / (\Gamma_{02} + i(\Delta_1 - \Delta_2)))\Gamma_{22})$ ,

$\rho_{F2}^{(2)} = -|G_2|^2 / ((\Gamma_{20} + i\Delta_2 + |G_1|^2 / (\Gamma_{21} - i(\Delta_1 - \Delta_2)))\Gamma_{22})$ . Where  $\rho_{F1}^{(2)} = |\rho_{F1}^{(2)}| e^{i\theta_{F1}}$ ,  $\rho_{F2}^{(2)} = |\rho_{F2}^{(2)}| e^{i\theta_{F2}}$ ,  $\theta_F = \theta_{F1} - \theta_{F2}$ . In  $\Lambda$ -type three-level system, the third-order density matrix elements  $\rho_{AS}^{(3)}$

via  $\rho_{11}^{(0)} \xrightarrow{E_1} \rho_{21}^{(1)} \xrightarrow{E_2} \rho_{22}^{(2)} \xrightarrow{E'_1} \rho_{20(AS)}^{(3)}$  can be written as

$\rho_{AS}^{(3)} = -iG_S G_1 G'_1 / ((\Gamma_{21} + i\Delta_1)(\Gamma_{22} + i\Delta_1 + |G_2|^2 / (\Gamma_{20} + i\Delta_1 - i\Delta_2))(\Gamma_{20} + i\Delta_1 + i\Delta'_1))$ . Where

$\rho_{AS1}^{(3)} = |\rho_{AS1}^{(3)}| e^{i\theta_{AS1}}$ ,  $\rho_{AS2}^{(3)} = |\rho_{AS2}^{(3)}| e^{i\theta_{AS2}}$ ,  $\theta_{AS} = \theta_{AS1} - \theta_{AS2}$ . The  $\Gamma_{ij} = (\Gamma_i + \Gamma_j)/2$  is the transverse

decay rate, where  $\Gamma_{i/j} = \Gamma_{pop} + \Gamma_{ion-spin} + \Gamma_{ion-ion} + \Gamma_{phonon} + \Gamma_{dressing} \cdot \Gamma_{phonon}$  is more related to broadband excitation.

In physics, the  $\rho_{F1}^{(2)}$  generated from the field  $E_1$  contains external field dressing  $|G_2|^2$ , and  $\rho_{F2}^{(2)}$  from the field  $E_2$  contains external field dressing  $|G_1|^2$ . So the  $|\rho_{F1}^{(2)} + \rho_{F2}^{(2)}|^2$  shows photon2 and photon1 dressing cross-interaction of FL signal [16] at profile  $E_1/E_2$  resonance in Figs. 3, 6 and 7. In Eqs. (2, 3), the  $|\rho_{AS1}^{(3)} + \rho_{AS2}^{(3)}|^2$  and  $|\rho_{F1}^{(2)} + \rho_{F2}^{(2)} + \rho_{AS1}^{(3)} + \rho_{AS2}^{(3)}|^2$  are similar to the  $|\rho_{F1}^{(2)} + \rho_{F2}^{(2)}|^2$  with two single external dressing. So, the  $|\rho_{AS1}^{(3)} + \rho_{AS2}^{(3)}|^2$  (Figs. (4-7)) and  $|\rho_H^x|^2$  (Fig. 7) show cross-interaction of SFWM and hybrid signals, respectively.

## B. Photon-phonon atomic coherence self-interaction

The self-term  $|\rho_{F2}^{(2)}|^2$  (or  $|\rho_{F1}^{(2)}|^2$ ) is taken from in Eq. (1) with external dressing. The phonon1 dressing  $|G_{p1}^T|^2$  and internal dressing  $|G_2|^2$  (or  $|G_1|^2$ ) are included in self-term

$|\rho_{F2}^{(2)}|^2 = -|G_2|^2 / ((\Gamma_{20} + i\Delta_2 + d_1)\Gamma_{00})^2$  with broadband  $E_1$  dressing (or  $|\rho_{F1}^{(2)}|^2 = -|G_1|^2 / ((\Gamma_{12} + i\Delta_1 + d_2)\Gamma_{22})^2$  with broadband  $E_1$  generation), where

$$d_1 = |G_{p1}^T|^2 / (\Gamma_{10} + i\Delta_2 - i\Delta_{p1}^j) + |G_1|^2 / (\Gamma_{21} + i\Delta_2 - i\Delta_1) \quad (\text{or})$$

$d_2 = |G_{p1}^T|^2 / (\Gamma_{10} + i\Delta_1 + i\Delta_{p1}^j) + |G_2|^2 / (\Gamma_{02} + i\Delta_1 - i\Delta_2)$ . For example, the  $|\rho_{F2}^{(2)}|^2$  with two cascade dressing is expanded as shown follows

$$|\rho_{F2}^{(2)}|^2 = |\rho_{F2}^{(2)} + \rho_{F2}^{(4)} + \rho_{F2}^{(4)}|^2. \quad (4)$$

The  $|\rho_{F2}^{(2)}|^2$  and  $|\rho_{F1}^{(2)}|^2$  contain  $|\rho_{F2}^{(2)}|^2 + 2|\rho_{F1}^{(2)}||\rho_{F2}^{(2)}|\cos(\Delta\varphi_{F2})$  in Eq. (4) and  $|\rho_{F1}^{(2)}|^2 + 2|\rho_{F1}^{(2)}||\rho_{F2}^{(2)}|\cos(\varphi_{F2})$ , which show out of phase FL2 and FL1 self-interaction of two lasers, respectively. However, when the external field dressing is neglected at off-resonance, the Eq. (4) becomes one laser self-interaction of FL.

The photon1 exciting atomic coherence ( $\Gamma_{12}$  and  $\rho_{12}$ ) between  $|1\rangle$  and  $|2\rangle$  couples to phonon1 atomic coherence by a common level  $|1\rangle$  (Fig. 1(b)) in  $|\rho_{F2}^{(2)}|^2$ . The photon2 excites atomic coherence ( $\Gamma_{20}$  and  $\rho_{20}$ ) between  $|0\rangle$  and  $|2\rangle$ . By Taylor expansion for cascade dressing, the dressing (atomic coherence) coupling effect is transferred into the nonlinear generating process in Eq. (4). Thus, we obtain the generating Hamiltonian

$$H = i\hbar\kappa_F\alpha_1^\dagger\alpha_2^\dagger\alpha_{p1}^\dagger + H.c. \text{ for sixth-order nonlinearity, where } \kappa_F = -i\omega_F\chi^{(6)}E_{FL}E_1E_2E_{p1}/2. \text{ The}$$

$\omega_F$  is the central frequency of FL.

Next, the difference from the self-term  $|\rho_{AS2}^{(3)}|^2$  (or  $|\rho_{AS1}^{(3)}|^2$ ) in Eq. (2), the internal dressing  $|G_2|^2$  (or  $|G_1|^2$ ) and two phonon dressing ( $|G_{p1}^T|^2$  and  $|G_{p2}^T|^2$ ) are included in

$$\rho_{AS2}^{(3)} \quad (\text{or } \rho_{AS1}^{(3)}). \text{ Where } \rho_{AS2}^{(3)} = -iG_{S2}G_2G_2/d_1 \quad (\text{or } \rho_{AS1}^{(3)} = -iG_{S1}G_1G_1/((\Gamma_{21} + i\Delta_1)d_5d_6)),$$

$$d = |G_2|^2 / (\Gamma_{20} + i\Delta_1 + |G_{p1}^T|^2 / (\Gamma_{01} + i\Delta_1 - i\Delta_{p1}^j) + |G_{p2}^T|^2 / (\Gamma_{31} + i\Delta_1 - i\Delta_{p2}^j + \Delta_{p2}^j)) ,$$

$$\begin{aligned}
d_1 &= (\Gamma_{20} + i\Delta_2 + d + |G_1|^2 / (\Gamma_{21} + i\Delta_2 - i\Delta_1))(\Gamma_{22} + i\Delta_2)(\Gamma_{20} + 2i\Delta_2) \\
d_2 &= |G_1|^2 / (\Gamma_{21} + i\Delta_1 + |G_{p1}^T|^2 / (\Gamma_{01} + i\Delta_1 - i\Delta_{p1}^j + |G_{p2}^T|^2 / (\Gamma_{31} + i\Delta_1 - i\Delta_{p1}^j + \Delta_{p2}^j))) , \quad d_3 = |G_2|^2 / (\Gamma_{20} + i\Delta_2 + i\Delta_1) , \\
d_4 &= \Gamma_{00} + i\Delta_1 , \quad d_5 = \Gamma_{20} + i\Delta_1' + i\Delta_1 , \quad d_6 = \Gamma_{22} + i\Delta_1 + d_2 + d_3 . \quad \text{The } |\rho_{AS2}^{(3)}|^2 \text{ with four cascade-nested} \\
&\text{dressing is expanded as shown follows}
\end{aligned}$$

$$|\rho_{AS1}^{(3)}|^2 = |\rho_{AS1}^{(3)} + \rho_{AS1}^{(5)} + \rho_{AS1}^{(7)} + \rho_{AS1}^{(9)}|^2 . \quad (5)$$

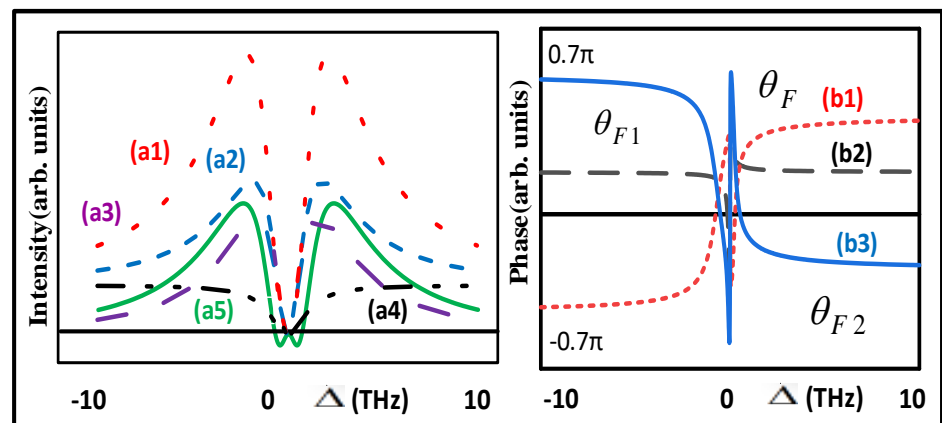
The in-phase anti-Stokes  $|\rho_{AS2}^{(3)}|^2$  and  $|\rho_{AS1}^{(3)}|^2$  contain  $|\rho_{AS2}^{(3)}|^2 + 2|\rho_{AS1}^{(3)}||\rho_{AS2}^{(3)}|\cos(\theta_{AS}^{(3)})$  in Eq. (5) and  $|\rho_{AS1}^{(3)}|^2 + 2|\rho_{AS1}^{(3)}||\rho_{AS2}^{(3)}|\cos(\theta_{AS}^{(3)})$ , which show anti-Stokes2 and anti-Stokes1 self-interaction of two lasers, respectively. When the external dressing is neglected at off-resonance, Eq. (5) becomes one laser self-interaction of anti-Stokes.

Phonon1 excites atomic coherence ( $\Gamma_{10}$  and  $\rho_{10}$ ) between  $|0\rangle$  and  $|1\rangle$ . Phonon2 excites atomic coherence ( $\Gamma_{31}$  and  $\rho_{31}$ ) between  $|1\rangle$  and  $|3\rangle$  (Fig. 1(b)). In four nested-cascade dressing of  $\rho_{s2}^{(3)}$ , the atomic coherence from nested coupling among photon1, phonon1 and phonon2, couples with atomic coherence of photon2 (Fig. 1(b)) in a cascaded manner. Similar to Eq. (4), the dressing coupling effect is transferred into the nonlinear generating process in Eq. (5). Thus, we also obtain the generating Hamiltonian can be written as

$$H_2 = i\hbar\kappa_{AS}\alpha_1^\dagger\alpha_2^\dagger\alpha_{p1}^\dagger\alpha_{p2}^\dagger + H.c. \quad \text{for} \quad \text{ninth-order} \quad \text{nonlinearity}, \quad \text{where}$$

$$\kappa_S = -i\omega_{AS}\chi^{(9)}E_{AS}E_SE_1E_2E_{p1}E_{p2}/2. \quad \text{The } \omega_{AS} \text{ is the central frequency of anti-Stokes.}$$

### C. Simulation of non-linear signals dressing interaction



**Fig. 2** (a1) The total signal intensity of  $|\rho_{F1}^{(2)}|^2 + |\rho_{F2}^{(2)}|^2$  (hot curve), (a2)  $|\rho_{F1}^{(2)}|^2$  (blue curve), (a3) the interaction item  $2|\rho_{F1}^{(2)}||\rho_{F2}^{(2)}|\cos(\theta)$  versus  $\Delta$  (purple curve), (a4)  $|\rho_{F2}^{(2)}|^2$  (black curve), (a5)  $|\rho_{sum}^{(2)}|^2$  (green curve). Fig. 2(b) Here  $\Delta = \Delta_1 - \Delta_2$ ,  $\theta = \theta_{F1} - \theta_{F2}$ . The parameters are  $G_1 = 2.3$  THz,  $G_2 = 6.1$  THz. (b1)  $\theta$  (hot curve), (b2)  $\theta_{F1}$  (black curve), (b3)  $\theta_{F2}$  (blue curve)

versus  $\Delta$ . Evolution of  $\theta_F$ , the constructive and the destructive interaction versus  $\Delta$ . Fig. 2(b)

The destructive or constructive interaction is studied in this system [23].

Figure 2(a) shows FL1 and FL2 self-terms  $|\rho_{F1}^{(2)}|^2 + |\rho_{F2}^{(2)}|^2$ , cross-term  $2|\rho_{F1}^{(2)}||\rho_{F2}^{(2)}|\cos(\theta_F)$  in cross-interaction of two lasers  $|\rho_{sum}^{(2)}|^2$  at  $\Delta_1 = \Delta_2/2$  versus the detuning difference

$\Delta = \Delta_1 - \Delta_2$  from Eq. (1).  $|\rho_{F1}^{(2)}|^2$  and  $|\rho_{F2}^{(2)}|^2$  have the maximal values at  $\Delta = \pm 4.1$  THz and

$\Delta = \pm 3.6$  THz, respectively. Hence, there exist two peaks at around  $\Delta = \pm 10$  THz in the hot curve that represents the cross-interaction  $|\rho_{sum}^{(2)}|^2$ . The purple curve shows the cross-term

$2|\rho_{F1}^{(2)}||\rho_{F2}^{(2)}|\cos(\theta_F)$ . Here the value below or above zero suggests destructive or constructive

interference, respectively. In fact, variations of the phase difference between second-order FL1 and FL2 change constructive interaction into destructive interaction, and vice versa.

Furthermore,  $\rho_{F1}^{(2)} = |\rho_{F1}^{(2)}|e^{i\theta_{F1}}$  and  $\rho_{F2}^{(2)} = |\rho_{F2}^{(2)}|e^{i\theta_{F2}}$ , we get

$|\rho_{F1}^{(2)} + \rho_{F2}^{(2)}|^2 = |\rho_{F1}^{(2)}|^2 + |\rho_{F2}^{(2)}|^2 + 2|\rho_{F1}^{(2)}||\rho_{F2}^{(2)}|\cos(\theta_F)$  from Eq. (1). Figure 2(b) shows the phases  $\theta_{F1}$ ,

$\theta_{F2}$ , and the phase difference  $\theta$  versus  $\Delta$ . As the  $\theta_{F1}$  and  $\theta_{F2}$  are changed, the  $\theta_F$

alternates between  $-0.7\pi$  and  $0.7\pi$ . The interaction switches from constructive ( $[-0.5\pi, 0.49\pi)$ ), destructive ( $[-0.7\pi, 0.5\pi)$ ), constructive ( $[-0.5\pi, 0.5\pi)$ ), and destructive

( $[0.5\pi, 0.7\pi)$ ) and constructive ( $[0.49\pi, 0.5\pi)$ ). In a word, our simulation (Fig.2) is obtained

by scanning  $\Delta = \Delta_2 - \Delta_1$  [23], and our experiment result (Figs. (3-7)) is gained by scanning the dressing field  $\Delta_2$ . For simplicity, we only considered the external dressing in simulation

(Eq. (1)). Furthermore, Eqs. (1-3) reveals the cross-interaction of two lasers. If the internal dressing and phonon dressing are considered, the cross-interaction become complicated.

## 2.2. Experiments

Photon excitation atomic coherence between different states ( $^5D_0$  and  $^7F_1$ ) can be coupled to phonon excitation atomic coherence in the same state ( $^7F_1$ ). Unlike photon atomic coherence of crystal field splitting with different states, the phonon atomic coherence of crystal field splitting in the same state is difficult to optically excite.

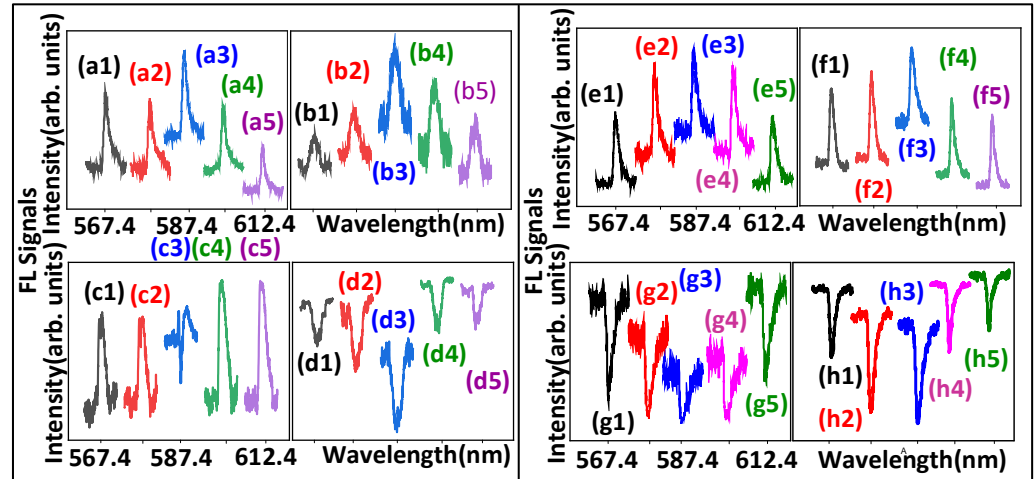
Moreover, the phonon dressing can control destructive and constructive interaction. The constructive interaction results from less phonon dressing (77K, M-phase, narrowband  $E_2$ ), whereas the destructive interaction is caused by more phonon dressing (300K, H-phase, broadband  $E_1$ ).

### A. FL dressing cross- and self-interaction

Figures (3-7) shows the connected spectrum of dressing cross-interaction of two lasers with different bandwidth. The spectrum profile of such interactions can be achieved by connecting several spectrums together by scanning  $\Delta_2/\Delta_1$  at different detuning ( $\Delta_1/\Delta_2$ ) and can be written as  $|\rho_{F/AS1} + \rho_{F/AS2}|^2 = R_1(\theta_{F/AS}) + N_1(\theta_{F/AS}) + R_2(\theta_{F/AS}) + N_2(\theta_{F/AS})$ . When the  $\Delta_i$  ( $i=1, 2$ ) is scanned, the  $R_i$  and  $N_i$  shows resonance and non-resonance profile term,



respectively. The broad peak ( $N_i(\theta_{F/AS} = 0)$  profile) and broad dip ( $N_i(\theta_{F/AS} = \pi)$  profile) in Figs. (3-7) show constructive and destructive interaction, respectively.



**Fig. 3** (a, c) show self- and cross- interaction of FL observed from  $\text{Eu}^{3+}$  doped  $\text{BiPO}_4$  [molar ratio (6:1)] at different  $E_1$  wavelengths (567.4nm, 584.4nm, 587.4nm, 589.4nm, 612.4nm) and  $E_2$  scanned from 567.4nm to 607.4nm at PMT1 (far detector position) and PMT2 (near detector position), respectively. Figures 3(b, d) show self- and cross- interaction of FL at different  $E_2$  wavelengths (567.4nm, 587.4nm, 588nm, 588.4nm, 602.4nm) and  $E_1$  scanned from 567.4nm to 612.4nm. Figures 3(e-h) show spectral signal intensity for (1:1) sample, which is same condition as Figs. 3(a-d). The time gate = 1 $\mu$ s.

Figures 3(a, b, e, f) show the constructive cross-interaction of FL (sharp peak  $R_i(\theta_F = 0)$ , broad peak  $N_i(\theta_F = 0)$  (profile)) at  $E_1/E_2$  resonance. When the time gate is fixed at 1 $\mu$ s, the FL emission is turn out to be dominant. The increasing sharp peaks at  $E_1$   $N_2(\theta_F = 0)$  (Figs. 3(a3, e3)) and  $E_2$   $N_1(\theta_F = 0)$  (Figs. 3(b3, f3)) resonance come from constructive cross-interaction due to  $|\rho_{F1}^{(2)} + \rho_{F2}^{(2)}|^2$  from Eq. (1). Such increasing sharp peak comes from the (6:1) sample and recorded at far detector position. Moreover, the broad peaks  $N_i(\theta_F = 0)$  in Figs. 3(a, e) and 3(b, f) come from single dressing constructive cross-interaction  $N_1(\theta_F = 0)$  and  $N_2(\theta_F = 0)$ , respectively, which agrees with two single external dressing simulations illustrated in Fig. 2(a3). The sharp peaks at  $E_1$  (Figs. 3(a, e)) and  $E_2$  (Figs. 3(b, f)) off-resonance result from self-interaction with internal dressing  $|G_2|^2$  and  $|G_1|^2$ , respectively.

Figure 3(c) shows the cross-interaction of FL (sharp dip  $R_2(\theta_F = \pi)$ ) and broad peak  $N_2(\theta_F = 0)$  at  $E_1$  resonance. Compared with the sharp peak (Fig. 3(c)) at  $E_1$  off-resonance, the dressing small dip  $R_2(\theta_F = \pi)$  at  $E_1$  resonance (Fig. 3(c3)) results from the switch of two cascade dressing (external photon  $|G_1|^2$  and phonon1  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^c) + |G_1|^2 / (\Gamma_{20} + i\Delta_1)$  in Eq. (4)). Moreover, the sharp peak  $R_2(\theta_F = 0)$  at  $E_1$  resonance (Fig. 3(a3)) is transferred into a small dip  $R_2(\theta_F = \pi)$  in Fig. 3(c3) due to phonon1 dressing  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^c)$  at near detector position (broadband FL). Similar to



Figs. 3(a, b, e, f), the broad peak in Fig. 3(c) results from constructive cross-interaction  $N_2(\theta_F = 0)$  with less phonon dressing.

Figures 3(d, g, h) show destructive cross-interaction of FL (sharp dressing dip  $R_1(\theta_F = \pi)$ ), broad dip  $N_1(\theta_F = \pi)$  (profile)) at  $E_1$  resonance. Compared with the sharp dip at  $E_2$  off-resonance from destructive self-interaction (Fig. 3(d)), the sharp dip at  $E_2$  resonance (Fig. 3(d3)) increases due to the destructive cross-interaction  $R_1(\theta_F = \pi)$  with external dressing  $|G_2|^2$  of  $\rho_{F1}^{(2)}$  in  $|\rho_{F1}^{(2)} + \rho_{F2}^{(2)}|^2$  at broadband excitation  $E_1$  and 300K. Because, the more crystal field splitting levels  $\gamma_{F1}$  (Fig. 1(b)) and lattice vibrations are coupled by broadband excitation  $E_1$ . Moreover, the 300K result in more thermal phonons with large  $G_{p1}^{T1}$ . The broad dip (Fig. 3(d)) comes from stronger destructive cross-interaction  $N_1(\theta_F = \pi)$  with more phonon dressing. The sharp dressing dips at  $E_2$  off-resonance (Fig. 3(d)) come from the self-interaction from Eq. (4).

The sharp dips at  $E_1$  off-resonance come from phonon1 dressing  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^c)$  of  $\rho_{F1}^{(2)}$  shown in Fig. 3(d). The sharp dip  $R_1(\theta_F = \pi)$  at  $E_1$  resonance results from cascade dressing  $|G_2|^2 + |G_{p1}|^2 / (\Gamma_{10} + i\Delta_2 + i\Delta_{p1}^d)$  of  $\rho_{F1}^{(2)}$  shown in Fig. 3(d3). Such cascade dressing coupling results in photon1-phonon2-phonon1 ( $\alpha_1^\dagger, \alpha_2^\dagger, \alpha_{p1}^\dagger$  in  $\chi^{(6)}$ ) atomic coherence coupling.

Figure 3(g) corresponds to the simulation (Fig. 5(g)) modelled through Eq. (4). Compared with the sharp dip at  $E_1$  off-resonance (Fig. 3(g)), the sharp dip at  $E_1$  resonance (Fig. 3(g3)) decreases due to the cross-interaction  $R_2(\theta_F = \pi)$  with phonon1 dressing  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^d) + |G_1|^2$  from Eq. (4) at narrowband excitation. The broad dip in Fig. 3(g) comes from strong destructive cross-interaction  $N_2(\theta_F = \pi)$  with more phonon dressing. Similar to Fig. 3(d), the broad dip (Fig. 3(h)) can be explained by stronger destructive cross-interaction  $N_1(\theta_F = \pi)$  with phonon1 dressing  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^d) + |G_2|^2$  of  $\rho_{F1}^{(2)}$ . Compared with small dip at  $E_1$  resonance (Fig. 3(c3)), the large dip is shown in Fig. 3(g3) due to phase transition phonon dressing  $|G_{p1}^{T1}|^2 / (i\Delta_{p1}^c + i\Delta_1) < |G_{p1}^{T1}|^2 / (i\Delta_{p1}^d + i\Delta_1)$ . Such phonon dressing dip results from resonance detuning  $\Delta_{p1}^d (\Delta_{p1}^d < \Delta_{p1}^c)$ , which is due to high phonon frequencies  $\omega_{p1}^d (\omega_{p1}^d > \omega_{p1}^c)$  for H-phase samples (6:1, 1:1) in Figs. 3(d, h).

The transistor as a peak amplifier<sup>1</sup> and dip amplifier<sup>2[24]</sup> shown in Fig. 1(d) is realized from spectral results observed in Figs. 3(b) and 3(d). In our proposed model, the FL signal is input ( $a_{in} = FL$ );  $E_2$  is a control signal (analogous to the base current of BJT), while  $a_{out}$  is the output of the

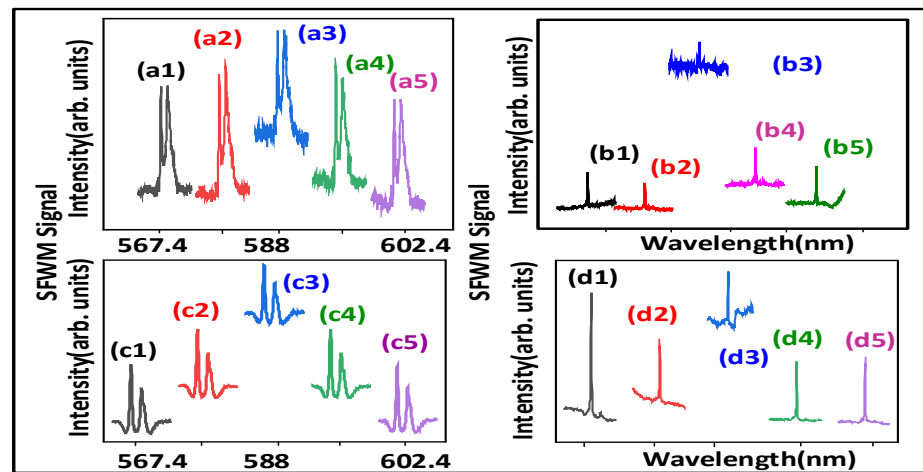
transistor, and transistor gain ( $g$ ) is related to external dressing effect and can be controlled through detuning of  $E_2$  beam. First, when  $E_2$  is set at off-resonance ( $\Delta_2 \neq 0$ ), the amplitude of both sharp peak (Fig. 3(b1)) and sharp dip (Fig. 3(d1)) is very low. When detuning of  $E_2$  approaches resonance ( $\Delta_2 = 0$ ), the amplitude of both sharp peak (Fig. 3(b3)) and dip (Fig. 3(d3)) amplifies by a factor of three. The amplification of spectral signals can be explained from high gain ( $g \gg 1$ ) caused by strong external dressing  $|G_2|^2$  at resonance wavelength.

Next, we extend our research and study the cross-interaction of SFWM in the following section B.

### B. SFWM dressing cross- and self-interaction

The out of phase FL (time gate=1 $\mu$ s) interaction is transferred to in-phase SFWM interaction (time gate=500 $\mu$ s). When the time gate is increased to 5 $\mu$ s, SFWM signal (sharp  $R_i$ ) is dominant.

Figures 4(a) show the constructive cross-interaction of SFWM (two sharp peaks  $R_1(\theta_{AS}=0)$ , broad peak  $N_1(\theta_{AS}=0)$  (profile)) at  $E_1$  resonance. Compared with two sharp peaks at  $E_2$  off-resonance (Fig. 4(a)), the two sharp peaks (Fig. 4(a3)) at  $E_2$  resonance also increase due to constructive interaction  $R_1(\theta_{AS}=0)$  with  $|\rho_{AS1}^{(3)} + \rho_{AS2}^{(3)}|^2$  in Eq. (2). Such two sharp peaks can be explained by crystal field splitting levels ( $|1\rangle, |0\rangle$ ) due to high resolution of in-phase SFWM. The broad peak comes from cross-interaction  $N_1(\theta_{AS}=0)$  in Fig. 4(a).



**Fig. 4** (a1-a5, b1-b5) show SFWM cross-interaction observed from  $\text{Eu}^{3+}$  doped  $\text{BiPO}_4$  [molar ratio (7:1)] at different narrowband laser  $E_2$  (567.4nm, 587.4nm, 588nm, 588.4nm, 602.4nm) while broadband laser  $E_1$  is scanned from 572.4nm to 612.4nm at different broadband laser  $E_1$  wavelengths (567.4nm, 584.4nm, 587.4nm, 596.4nm, 612.4nm) and narrowband laser  $E_2$  is scanned from 567.4nm to 607.4nm at 300K, respectively at PMT1. The time gates are 5 $\mu$ s and 20 $\mu$ s, respectively, gate width=400ns. Figure 4(c, d) shows SFWM cross-interaction for the (20:1) sample at the time gate =10 $\mu$ s and 20 $\mu$ s, respectively. The other experimental condition is the same as Figs. 4(a, b), respectively at PMT1.

Figures 4(b, d) show the constructive cross-interaction of SFWM (single sharpest peak  $R_2(\theta'_{AS}=0)$ , broad peak  $N_2(\theta'_{AS}=0)$ ) at  $E_1$  resonance. Compared with the sharpest peak at  $E_1$  off-resonance (Fig. 4(b)), the amplitude of sharpest peak  $R_2(\theta'_{AS}=0)$  at  $E_1$  resonance (Fig. 4(b3)) decreases due to constructive cross-interaction with phonon1-assisted  $G_2$  dressing ( $G_{p1}^{T2}$  and  $G_2$  share the common atomic coherence)

$(|G_1|^2 + |G_{p1}^T|^2) / (\Gamma_{10} + i\Delta_1 + i\Delta_{p1}^a)$  of  $\rho_{AS2}^{(3)}$ . Compared with sharp peak (Fig. 4(a3)), the linewidth of such sharpest peak decreases due to less thermal phonon (77K) with small  $G_{p1}^{T2}$ . The broad peak comes from constructive interaction  $N_2(\theta'_{AS}=0)$  in Fig. 4(b) with less phonon dressing. However, the sharpest peak (Fig. 4(b)) at  $E_1$  off-resonance is due to self-interaction.

Figure 4(c) shows the constructive cross-interaction of SFWM (two sharp peaks  $R_1(\theta''_{AS}=0)$ , broad peak  $N_1(\theta''_{AS}=0)$ ) at  $E_2$  resonance. The proportion of the two sharp peaks accounts for roughly of 80% and the proportion of single sharp dips only accounts for roughly of 20% in Fig. 4(c). Compared with two sharp peaks at  $E_2$  off-resonance in Fig. 4(c), such two sharp peaks (Fig. 4(c3)) at  $E_2$  resonance decrease due to constructive cross-interaction  $R_1(\theta''_{AS}=0)$ . The broad peak comes from constructive interaction  $N_1(\theta''_{AS}=0)$  in Fig. 4(c). The small sharp dip (Fig. 4(c3)) at  $E_2$  resonance is obtained from destructive cross-interaction due to phonon1 dressing  $|G_{p1}^T|^2 / (\Gamma_{10} + i\Delta_2 + i\Delta_{p1}^b) + |G_2|^2$  in Eq. (5).

Compared with two sharp peaks at  $E_2$  resonance for the (7:1) sample (Fig. 4(a3)), the small sharp dip at  $E_2$  resonance is shown in Fig. 4(c3)) due to phonon dressing ( $\Delta_{p1}^a > \Delta_{p1}^b$ ,

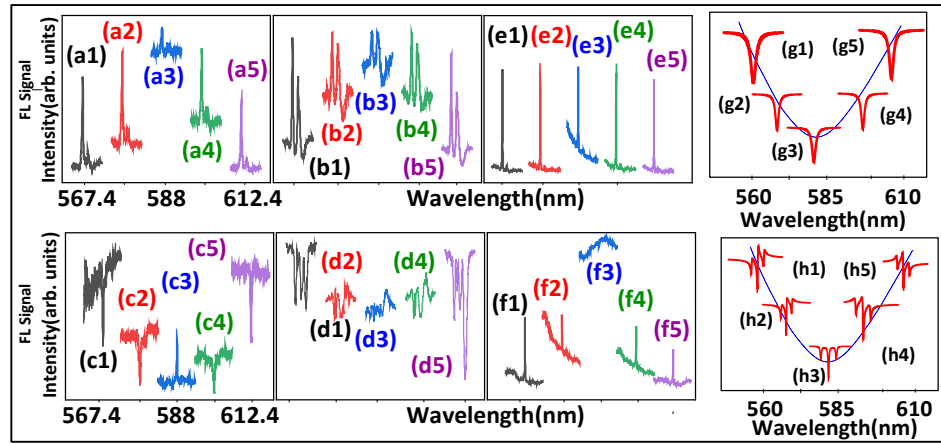
$|G_{p1}^{T2}|^2 / i\Delta_{p1}^a < |G_{p1}^{T2}|^2 / i\Delta_{p1}^b$ ) for more H-sample (20:1). Such small sharp dip result from the

switch of two cascade dressing (external photon  $|G_2|^2$  and phonon1  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^b) + |G_2|^2$  of  $\rho_{AS1}^{(3)}$ ). Because the phonon dressing is easily distinguished by in-phase SFWM.

Similar to Fig. 4(b3), the sharpest peak at  $E_1$  resonance also decreases due to constructive cross-interaction  $R_2(\theta'_{AS}=0)$  with phonon1-assisted dressing in Fig. 4(d3).

Figures 5(a) show the constructive cross-interaction of SFWM (sharp peak  $R_2(\theta_{AS}=0)$ , and broad peak  $N_2(\theta_{AS}=0)$ ) at  $E_1$  resonance. Similar to Figs. 4(b, d), the sharp peak (Fig. 5(a3)) at  $E_1$  resonance decreases as compared to the sharp peaks at  $E_1$  off-resonance (Fig. 5(a)) due to cross-interaction  $R_2(\theta_{AS}=0)$  with phonon1-assisted dressing

$(|G_1|^2 + |G_{p1}^{T1}|^2) / (\Gamma_{10} + i\Delta_1 + i\Delta_{p1}^c)$  of  $\rho_{AS2}^{(3)}$ . The broad peak at  $E_1$  off-resonance comes from constructive interaction  $R_2(\theta_{AS}=0)$  due to less phonon dressing.



**Fig. 5** (a, c) show SFWM cross- interaction observed from  $\text{Eu}^{3+}$  doped in molar ratio (6:1)  $\text{BiPO}_4$  at different  $E_1$  wavelengths (567.4nm, 584.4nm, 588.4nm, 596.4nm, 612.4nm) and  $E_2$  scanned from 567.4nm to 607.4nm at PMT1 and PMT2 at 300K, respectively. (b, d) shows SFWM cross- interaction at different  $E_2$  wavelengths (567.4nm, 587.4nm, 588nm, 588.4nm, 602.4nm) and  $E_1$  scanned from 567.4nm to 612.4nm at PMT1 and PMT2 in 300K, respectively. (e, f) shows SFWM cross-interaction at 77K. The other experimental conditions are same as Figs. 5(a, c), respectively. Time gate = 500 $\mu$ s. Figures. 5(g1-g5) show the simulation result corresponding to Figs. 5(b1-b5). Figures. 5(h1-h5) show the simulation result corresponding to Figs. 3(g1-g5) and 7(e1-e5).

Figures 5(b) show the constructive cross-interaction of SFWM (two sharp peaks  $R_1(\theta''_{AS}=0)$ , broad peak  $N_1(\theta''_{AS}=0)$ ) at  $E_2$  resonance. Compared with the small dip at  $E_2$  resonance (Fig. 4(c3)), the small dip at  $E_2$  resonance (Fig. 5(b3)) increases due to cross-interaction  $R_1(\theta''_{AS}=0)$  with phonon1 dressing  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_2 + i\Delta_{p1}^c)$  in Eq. (5). Such small

sharp dip results from the switch of two cascade dressing  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^c) + |G_2|^2$  of  $\rho_{AS1}^{(3)}$ .

The broad peak in Fig. 5(b) comes from constructive cross-interaction  $N_1(\theta''_{AS}=0)$  due to less phonon dressing.

Figures 5(c) show the cross-interaction of SFWM (sharp peak  $R_2(\theta''_{AS}=0)$ , broad dip  $N_2(\theta''_{AS}=0)$  (profile)) at  $E_1$  resonance. The sharp dip at  $E_1$  off-resonance (Fig. 5(c)) is transferred into the sharp peak at  $E_1$  resonance (Fig. 5(c3)) due to constructive cross-interaction  $R_2(\theta''_{AS}=0)$  with phonon1 dressing  $|G_{p1}^{T1}|^2 + |G_1|^2$  of  $\rho_{AS1}^{(3)}$  at narrowband excitation. Such transition (sharp dip  $R_2(\theta''_{AS}=\pi)$  to sharp peak  $R_2(\theta''_{AS}=0)$ ) results from the switch of three cascade dressing (internal photon  $G_2$ , external photon  $G_1$  and phonon1  $G_{p1}$  of  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^c) + |G_1|^2 + |G_2|^2$  in  $|\rho_{AS1}^{(3)} + \rho_{AS2}^{(3)}|^2$ ). The broad dip comes from strong constructive interaction  $N_1(\theta''_{AS}=\pi)$  in Fig. 5(c) with more phonon dressing. More interestedly, the sharp dips at  $E_1$  off-resonance (Fig. 5(c)) result from self-interaction in Eq. (5). Such sharp dips are obtained from 300K due to more thermal phonon dressing (large  $G_{p1}^{T1}$ ). Compared with the sharpest peak at  $E_1$  off-

resonance for (7:1) and (20:1) sample (Fig. 4(c, d)), the sharp dip at  $E_1$  off-resonance (Fig. 5(c)) decreases due to phase transition phonon dressing ( $|G_{p1}^{T1}|^2 / i\Delta_{p1}^c > |G_{p1}^{T2}|^2 / i\Delta_{p1}^{ab}$ ) for (6:1) more H-phase sample.

Figures 5(d) show the destructive cross-interaction of SFWM (three sharp dips  $R_1(\theta_{AS}' = \pi)$ , broad dip  $N_1(\theta_{AS}'' = \pi)$ ) at  $E_2$  resonance. Difference with three sharp dips at  $E_2$  off-resonance from destructive self-interaction (Eq. (5)) in Fig. 5(d), the three sharp dips at  $E_2$  resonance in Fig. 5(d3) result from destructive cross-interaction  $R_1(\theta_{AS}' = \pi)$  with phonon1 and phonon2 dressing. The broad dip in Fig. 5(d) is obtained from stronger destructive cross-interaction  $N_1(\theta_{AS}'' = \pi)$  with more phonon dressing at 300K and broadband excitation. Figure 5(d) corresponds to the simulation result (Fig. 5(h)) from Eq. (5).

The three sharp dips at  $E_2$  off-resonance (Fig. 5(d)) result from three nested dressing (internal photon  $G_1$ , two phonons). However, the decreasing three sharp dips  $R_1(\theta_{AS}' = \pi)$  at  $E_2$  resonance (Fig. 5(d3)) come from external dressing  $|G_2|^2$  of four nested-cascade dressing (internal photon  $G_1$ , external photon  $G_2$  and two phonons)

$$|G_1|^2 / (\Gamma_{20} + |G_{p1}^{T1}|^2 / (\Gamma_{10} - i\Delta_{p1}^c + |G_{p2}^{T1}|^2 / (\Gamma_{13} - i\Delta_{p1}^c - i\Delta_{p2}^c))) + |G_2|^2 \text{ of } \rho_{AS1}^{(3)} \text{ (Eq. (5)) in } |\rho_{AS2}^{(3)} + \rho_{AS1}^{(3)}|^2.$$

Such four dressing coupling results from photon1-phonon2-phonon1-phonon2 ( $\alpha_1^\dagger, \alpha_2^\dagger, \alpha_{p1}^\dagger, \alpha_{p2}^\dagger$  in  $\chi^{(9)}$ ) atomic coherence coupling.

The more phonon dressing result from more lattice vibrations at 300K for  $\text{Eu}^{3+}$ :  $\text{BiPO}_4$  than other samples ( $\text{Eu}^{3+}/\text{Pr}^{3+}$ :  $\text{YPO}_4$  [24] and  $\text{Pr}^{3+}$ :  $\text{Y}_2\text{SO}_5$  [25]). The model for phonon-controlled transistor switch is presented in Fig. 1(d) where 'enhancement peak' and 'suppression dip' corresponds to 'ON-state' and 'OFF-state', respectively. When the input signal (Fig. 3(b3)) is in single ON-State (higher than baseline) then the corresponding output signal (Fig. 3(d3)) is at single OFF-State (lower than baseline). Such spectral switch can be controlled by single phonon dressing ( $|G_{p1}|^2$ ). Our experiment result defined the switching

contrast as  $C = (I_{\text{off}} - I_{\text{on}}) / (I_{\text{off}} + I_{\text{on}})$ , where  $I_{\text{off}}$  is the intensity at the OFF-state and  $I_{\text{on}}$  is the intensity at the ON-state. The maximum switching contrast  $C$  for single state switch is about 82% in Fig. 3(b3) and 3(d3). Furthermore, when the ON-state of input signal is observed with two sharp peaks (Fig. 5(b3)) the corresponding output signal has OFF-state with three sharp dips as observed in Fig. 5(d3). Such multi-states switch can be controlled by two phonon dressing ( $|G_{p1}|^2, |G_{p2}|^2$ ). The switching contrast  $C$  is about 93.6% for multi-states switch measure for Figs. 5(b3) and Fig. 5(d3).

Figures 5(e, f) show the constructive cross-interaction of SFWM (single sharpest peak  $R_2(\theta_{AS}' = 0)$ , broad peak  $N_2(\theta_{AS}'' = 0)$ ) at  $E_1$  resonance. Compared with the sharpest peaks at  $E_1$  off-resonance in Fig. 5(e), the sharpest peak  $R_2(\theta_{AS}' = 0)$  at  $E_1$  resonance in Fig. 5(e3) increases due to constructive cross-interaction with phonon1-assisted dressing

$(|G_1|^2 + |G_{p1}^{T2}|^2) / (\Gamma_{10} + i\Delta_1 + i\Delta_{p1}^e)$  of  $\rho_{AS2}^{(3)}$  at 77K. Figure 5(g) shows simulation results corresponding to experimental result (Fig. 5(b)). The transition from broad dip  $N_2(\theta'_{AS} = \pi)$  (Fig. 5(c)) to broad peak  $N_2(\theta'_{AS} = 0)$  (Fig. 5(f)) is due to the reduction of phonon dressing. So, thermal phonon dressing plays a key role in cross-interaction.

In order to explore more, we further compare the FL and SFWM interaction in section C.

### C. Comparison of FL and SFWM interaction

The cross-interaction in Figs. 6-7 evolves from out of phase FL to hybrid (coexistence of second order FL and SFWM), to in-phase SFWM by changing the time gate (1μs to 500μs) obtained from (0.5:1) sample.

Figures 6(a-b) show the constructive cross-interaction of FL (sharp peak  $R_1(\theta_F = 0)$ , broad peak  $N_1(\theta_F = 0)$ ) at  $E_2$  resonance. Similar to Fig. 3(a3, b3, e3, f3), the increasing sharp peaks (Fig. 6(a3)) at  $E_2$  resonance is due to constructive cross-interaction  $R_1(\theta_F = 0)$  in Eq. (1). Compared with sharp peak at  $E_2$  off-resonance (Fig. 6(b)), the sharp peak  $R_1(\theta_F = 0)$  at  $E_2$  resonance (Fig. 6(b3)) decreases due to phonon1-assisted dressing  $(|G_2|^2 + |G_{p1}^{T1}|^2) / (\Gamma_{10} + i\Delta_2 + i\Delta_{p1}^e)$  of  $\rho_{F1}^{(3)}$  (similar to Fig. 5(a)).

Figures 6(c-d) show the constructive cross-interaction of SFWM (two sharpest peaks  $R_1(\theta'_{AS} = 0)$ , broad peak  $N_1(\theta'_{AS} = 0)$ ) at  $E_2$  resonance. When the time gate increases to 500μs, compared with two sharpest peaks at  $E_2$  off-resonance in Figs. 6(c, d), two sharpest peaks  $R_1(\theta'_{AS} = 0)$  at  $E_2$  resonance in Figs. 6(c3, d3) decreases due to phonon1-assisted dressing  $(|G_2|^2 + |G_{p1}^{T2}|^2) / (\Gamma_{10} + i\Delta_2 + i\Delta_{p1}^e)$  in  $\rho_{AS1}^{(3)}$  (similar to Figs. 4(c3) and 5(a3)). The spectral linewidth of sharp peak in Fig. 6(a1) at 300K is 9 times larger than the linewidth at 77K in Fig. 6(c1) due to more thermal phonon dressing  $(|G_{p1}^{T1}|^2 / i\Delta_{p1}^e > |G_{p1}^{T2}|^2 / i\Delta_{p1}^e)$ .

Similar to sharp peak with (6:1) sample at 300K (large  $G_{p1}^{T1}$ ) in Figs. 5(a, b), the two sharpest peaks with (0.5:1) sample are also shown at 77K (small  $G_{p1}^{T2}$ ) in Figs. 6(c, d) due to phase phonon dressing  $|G_{p1}^{T2}|^2 / (i\Delta_{p1}^e + i\Delta_1)$  from resonance detuning  $(\Delta_{p1}^e \approx 0)$ . Therefore, compared with out of phase FL (Figs. 6(a, b)), in-phase SFWM is more sensitive to phonon dressing (Figs. 6(c, d)).



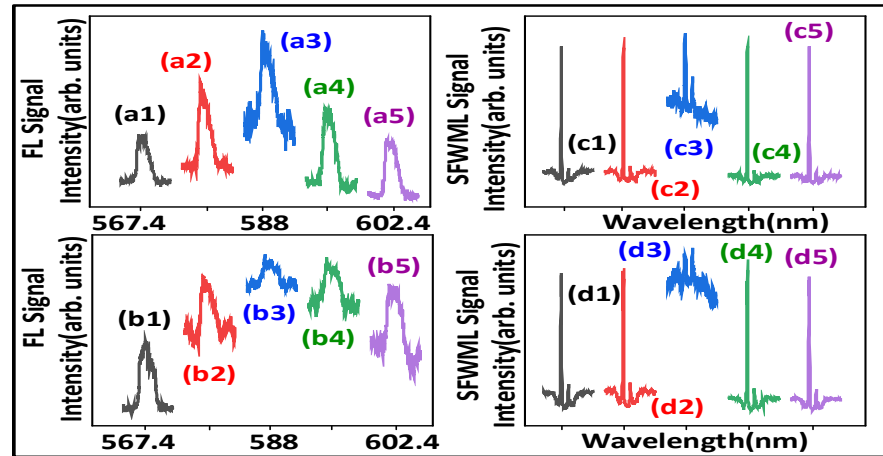


Fig. 6 (a, b) show FL cross-interaction observed from the output signals of  $\text{Eu}^{3+}$  doped in molar ratio (0.5:1)  $\text{BiPO}_4$  at different  $E_2$  wavelengths (567.4nm, 587.4nm, 588nm, 588.4nm, 602.4nm) and  $E_1$  scanned from 572.4nm to 612.4nm at 300K, at PMT1 and PMT2, respectively. The time gate is 10 $\mu\text{s}$ . Figures 6(c, d) show SFWM cross-interaction at 77K at the time gate = 800 $\mu\text{s}$ , respectively. The other experimental condition is the same as Figs. 6(a, b).

Figures 7(a, b) show the constructive cross-interaction of FL (sharp peak  $R_2(\theta_F = 0)$ , broad peak  $N_2(\theta_F = 0)$ ) at  $E_1$  resonance. When the time gate is fixed at 1 $\mu\text{s}$ , compared with sharp peak at  $E_1$  off-resonance in Fig. 7(a), the sharp peak  $R_2(\theta_F = 0)$  at  $E_1$  resonance in Fig. 7(a3) increases (similar to Fig. 6(a)). The sharp peak  $R_2(\theta_F = 0)$  at  $E_1$  resonance in Fig. 7(b3) decreases as compare to the sharp peaks at  $E_1$  off-resonance in Fig. 7(b) due to phonon1-assisted dressing ( $|G_1| + |G_{p1}^{T1}|$ )<sup>2</sup> / ( $\Gamma_{21} + i\Delta_1 + i\Delta_{p1}^e$ ) of  $\rho_{F2}^{(2)}$ .

Figures 7(c, d) show the constructive cross-interaction of hybrid (single sharpest peak  $R_2$ , broad peak  $N_2$ ) at  $E_1$  resonance. When the time gate increases to 100 $\mu\text{s}$ , difference with the sharpest peak at  $E_1$  off-resonance in Figs. 7(c, d), the sharpest peaks  $R_2$  at  $E_1$  resonance in Figs. 7(c3, d3) decrease due to constructive cross-interaction with phonon1-assisted dressing of  $R_2$  in Eq. (3). The broad peaks  $N_2$  in Figs. 7(c, d) can be explained by constructive cross-interaction with less phonon dressing.

Figure 7(e) shows the destructive cross-interaction of SFWM (single sharpest dips  $R_2(\theta_{AS} = \pi)$ , broad dip  $N_2(\theta_{AS} = \pi)$ ) at  $E_1$  resonance. When the time gate reaches to 500 $\mu\text{s}$ , difference with sharpest dip at  $E_1$  off-resonance, the sharpest dip  $R_2(\theta_{AS} = \pi)$  at  $E_1$  resonance in Fig. 7(e3) decreases due to stronger destructive cross-interaction with phonon1 dressing. Such decreasing sharpest dip  $R_2(\theta_{AS} = \pi)$  results from external dressing  $|G_1|^2$  of two cascade dressing  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^d) + |G_1|^2$  in  $\rho_{AS2}^{(3)}$ . Moreover, the broad dip  $N_2(\theta_{AS} = \pi)$  is obtained from 300K and (0.5:1) sample with more phonon dressing.

Similar to Fig. 5(c), figure 7(f) shows the cross-interaction of SFWM (single sharpest peak  $R_2(\theta_{AS}''=0)$ , broad dip  $N_2(\theta_{AS}''=\pi)$  at  $E_1$  resonance. Difference with sharp dip at  $E_1$  off-resonance in Fig. 7(f), the sharpest peak at  $E_1$  resonance is shown in Fig. 7(f3) due to constructive cross-interaction  $R_2(\theta_{AS}''=0)$  with less phonon dressing. Such transition (sharpest dip  $R_2(\theta_{AS}''=\pi)$  to sharpest peak  $R_2(\theta_{AS}''=0)$ ) results from the switch of three cascade dressing  $|G_{p1}^{T1}|^2 / (\Gamma_{10} + i\Delta_{p1}^e) + |G_1|^2 + |G_2|^2$  of  $\rho_{AS2}^{(3)}$ . Similar to Fig. 5(c), the broad dip (Fig. 7(f)) comes from strong destructive cross-interaction  $N_2(\theta_{AS}''=\pi)$  with more phonon dressing.

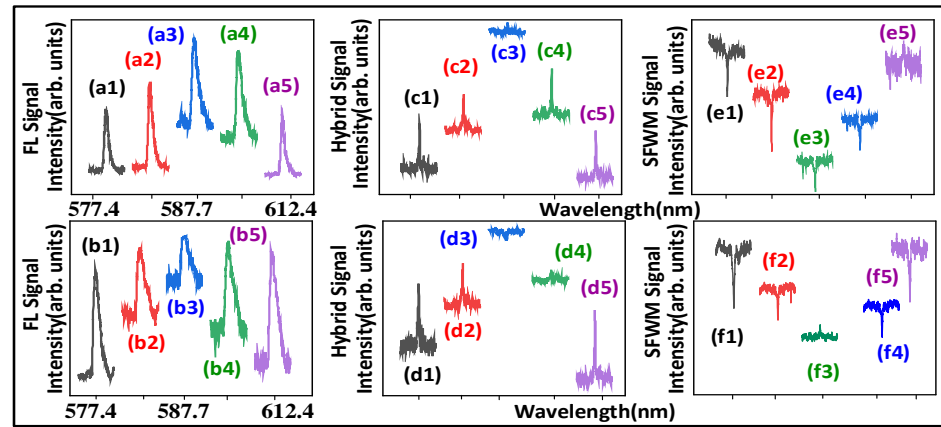


Fig. 7 (a, b) show FL cross-interaction observed from  $\text{Eu}^{3+}$  doped in molar ratio (0.5:1)  $\text{BiPO}_4$  at different  $E_1$  wavelengths (577.4nm, 584.4nm, 587.7nm, 592.4nm, 612.4nm) and  $E_2$  scanned from 567.4nm to 607.4nm at PMT1 and PMT2, respectively, at the near time gate (1 $\mu\text{s}$ ). Figures 7(c-d) show hybrid cross-interaction at the middle time gates (100 $\mu\text{s}$ ). Figures 7(e-f) show SFWM cross-interaction at the far time gate (500 $\mu\text{s}$ ). The other experimental condition is the same as Figs. 7(a, b), respectively.

Therefore, the out of phase FL constructive interaction (Figs. 7(a, b)) can be evolved to in-phase SFWM destructive interaction (Figs. 7(e, f)). The H-phase result (Figs. 5-6) comes from sensitive phonon dressing and easy distinction for in-phase SFWM.

Moreover, the linewidth of peak increases from  $0.4 \pm 0.1 \text{ nm}$  in Fig. 7(c) to  $4.7 \pm 0.1 \text{ nm}$  in Fig. 7(a) due to the  $\Gamma_{\text{phonon}}$  of generating process. The width with dressing dip increases from  $0.6 \pm 0.1 \text{ nm}$  in Fig. 5(d) to  $5.9 \pm 0.2 \text{ nm}$  in Fig. 3(d) due to the  $\Gamma_{\text{phonon}}$  of dressing process. The destructive cross-interaction  $R_i$  in Fig. 3(d) and 5(d) results from more phonon dressing with same area. However, such more phonon dressing shows different phenomena for single sharp FL dip in Fig. 3(d) and three sharpest SFWM dips in Fig. 5(d).

### 3. Discussion

From our results we conclude that unlike cross-interaction  $N_i$  [non-resonance], the

internal and external dressing atomic coherence coupling result in switching between constructive to destructive for  $R_i$  (Figs. 3(c), 4(b), 5(b, c), 7(f)). The resonant cross-interaction  $R_i$  is distinguished from non-resonant cross-interaction  $N_i$  without internal dressing.

Furthermore, the destructive interactions result from cascade dressing (Figs. 3(d, e, f), 4(c), 5(b, c), 7(e)) and four nested-cascade dressing (Fig. 5(d)), respectively. The cascade dressing and nested dressing suggest strong and stronger photon-phonon atomic coherence coupling (leading to three dressing dips shown in Fig. 5(d)), respectively.

#### 4. Conclusion

In summary, we theoretically and experimentally studied constructive and destructive photon-phonon atomic coherence interaction. The destructive spectral interactions result from cascade dressing and four nested-cascade dressing, respectively. The cascade dressing with strong photon-phonon atomic coherence coupling lead to the single sharp dip. Moreover, the four nested-cascade dressing with stronger photon-phonon atomic coherence coupling lead to three sharp dips. The transistor as an amplifier and switch were realized by photon-phonon atomic coherence interaction, which could have potential applications in atomic-like systems.

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**Data Availability Statement:** Data underlying the results presented in this paper are not publicly available at this time but may be obtained from the authors upon reasonable request.

**Conflicts of Interest:** The authors declare no conflict of interest.

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